Midterm 3 Review
Light as Wave

• The propagation of light can best be described as a travelling wave.
• It really is a coupled electric and magnetic field that oscillate together in time and space (electromagnetic wave).

\[ y = A \cos(kx - \omega t) \]

- \[ c = 3 \times 10^8 \text{ m/s} \] Speed of Light
- \[ \omega = 2\pi f \] Angular Frequency
- \[ k = \frac{2\pi}{\lambda} \] Wavenumber
- \[ T \] Period (s)
- \[ \lambda \] Wavelength (m)
- \[ f = \frac{1}{T} \] Frequency (Hz)
Electromagnetic Spectrum
Polarization

• We said that light is a wave with an electric and a magnetic field. These fields are vector quantities, which means they have a direction as well as an amplitude.
• The direction of the electric field associated with the EM wave is called its polarization.
• Light can be linearly (horizontal or vertical) or circularly (clockwise or counter cw) polarized or unpolarized (random polarization).
• Laser light is generally polarized while sunlight and light from light bulbs are unpolarized.
• Unpolarized light can be turned into polarized light by a polarizer.
• A polarizer can work by;
  – selective absorption (polaroid films, sunglasses)
  – selective scattering (blue skies, red sunsets)
  – reflection (Brewster’s angle, ellipsometry)
  – double refraction (calcite crystals)
Interference

- If the waves are emitted from a single source, we can adjust the synchronicity of the waves by adjusting their arrival times.
- If one wave arrives half a period of oscillation after the other, then it will be completely out of sync with the earlier one and they will cancel each other out – **destructive interference**.
- The same is true for any wave that arrives 1.5 periods later and 2.5 periods later, etc.
- If one wave arrives exactly a period later then it will be again completely in sync with the earlier one and they will add to each other – **constructive interference**.
- Same is true for all waves arriving 2 periods, 3 periods, etc. later.
Thin Film Interference

- Consider a thin film that is at least partially transparent to light.
- If light is incident from the top, some of the light will be reflected and some will be transmitted into the film.
- Similarly, as the transmitted light tries to exit the film at the bottom, there will be reflection and transmission.
- The waves that were reflected from the top of the film and the bottom of the film will interfere with each other.
- If the delay introduced by the thickness of the film matches an integer multiple of the period of light, there will be constructive interference.
- If it is half a period of delay, there will be destructive interference.
- One additional wrinkle is that waves that reflect off of a higher index medium will undergo a 180° phase change so that a delay of one period results in destructive interference and a delay of half a period results in constructive interference.
Diffraction

- Diffraction occurs because light waves that go through an opening (or around an obstruction) interfere with themselves.
- This results in a series of constructive and destructive interference bands.
- Most of the light intensity is in the central bright band.
- The width of the band is inversely proportional to the width of the opening and directly proportional to the wavelength of the light.

\[ \lambda \approx \frac{L}{a} \]
Non-linear Optics

- When light passes through a material, it interacts with the atoms around it.
- The electric field associated with the light wave will distort the electrons in their orbits creating a polarized state.
- The material polarization in turn affects the light propagating through it.
- For low intensity light, this polarization is linearly dependent on the electric field and only the intensity of the light changes.
- However, for high intensity light waves, the dependence becomes non-linear.
- The non-linearity creates harmonics of the light wave.

The incident electric field

\[ E = E_0 \cos \omega t \]

The polarization response of the material

\[ P = a_1 E + a_2 E^2 + a_3 E^3 + \ldots \]

Second Harmonic Generation

\[ P = a_2 E^2 = a_2 (E_0 \cos \omega t)^2 \]

\[ P = a_2 E_0^2 \cos^2 \omega t = a_2 E_0^2 (1 + 2 \cos 2\omega t) \]

2\text{nd Harmonic at } 2\omega
Light as a Particle

- In its interactions with matter (atoms and/or molecules), light can be described as a particle called a photon.

\[
\begin{align*}
    c &= \lambda f \\
    E &= hf
\end{align*}
\]

- \[c = 3 \times 10^8 \text{ m/s}\]  \text{Speed of Light}
- \[h = 6.6262 \times 10^{-34} \text{ J.s}\]  \text{Planck's Constant}
- \[1 \text{eV} = 1.6 \times 10^{-19} \text{ J}\]  \text{electron-volt}

\[E \lambda \approx 1240\]

- Light energy in eV
- Light wavelength in nm
Absorption and Luminescence

• External energy can be supplied to a material by
  – electrical current (electroluminescence)
  – optical excitation (photoluminescence)
  – electrical discharge (cathodoluminescence)

• When external energy is absorbed in a material, the excited electrons can return to their ground states by releasing the absorbed energy as light.

• This light can come from direct level to level transitions or from defects.

Absorption

<table>
<thead>
<tr>
<th>High energy light excites electrons to a higher energy level</th>
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Relaxation

<table>
<thead>
<tr>
<th>The electrons relax to a lower level</th>
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</table>

Emission

<table>
<thead>
<tr>
<th>The electrons return to their ground state and emit light at a lower energy.</th>
</tr>
</thead>
</table>
Lattice Vibrations

- Atoms making up a crystal lattice can vibrate or rotate in their place.
- These oscillations can be thought of individual entities, called **phonons**, that have a characteristic oscillation frequency and energy \( E = hf \).
- The energy of the vibration is dependent on the composition of the crystal and the chemical bonds.
- Lattice vibrations are also how sound waves propagate through materials.
- If the vibrations are in the direction of the lattice, they are called longitudinal vibrations.
- If they are in perpendicular to the direction of the lattice, they are transverse vibrations.
- Transverse vibration energies are in the order of tens of meV.
Raman Scattering

- The Raman effect arises when the incident light excites molecules in the sample which subsequently scatter the light.
- While most of this scattered light is at the same wavelength as the incident light, some is scattered at a different wavelength.
- This *inelastically* scattered light is called Raman scattering.
- The main medium for this energy change are the lattice vibrations.
Spectrometers

Source -> Entrance Slit -> Collection lens -> Diffraction Grating -> Exit Slit -> Detector
Absorption Spectroscopy

- Measures the absorption coefficient.
- The result is a combination of a number of processes that go on in the sample.
Fluorescence Spectroscopy

- The laser excites an electronic transition.
- Light at various wavelengths are emitted as the electrons relax and return to their ground states.
- It is sensitive to electronic transitions.
Excitation Spectroscopy

• Same setup but now change the excitation wavelength and detect at a single wavelength.

• Used for precision measurement of molecular absorption lines.
Raman Spectroscopy

- The setup is similar to fluorescence spectroscopy.
- However, since the Raman scattering lines are very close to the laser excitation, narrow band lasers, precision filters and double monochromators are used.
- Raman scattering results from the change of the excitation laser wavelength by lattice vibrations.
- The lattice vibrations are sensitive to the chemical bonds in the sample.
- It is used in chemical analysis, process control and thin film quality measurements.
- The units are in wavenumbers \( k = 2\pi/\lambda \).
Michelson Interferometer

- The idea is to detect the difference in the arrival times of two beams by their interference.
- The arrival time is also equivalent to path length.
- This technique can be used to test surface quality and flatness.
Fabry-Perot Interferometer

- It is based on thin film interference.
- Since constructive and destructive interference is dependent on the wavelength of the light and the length of the interferometer, it can be a very precise method of wavelength measurement.
- The reflectivities of the surfaces determine the \textit{finesse} of the interferometer (the sharpness of the transmitted lines)
FTIR Spectroscopy

- Fourier Transform Infra-Red Spectroscopy
- It is a combination of IR absorption spectroscopy and a Michelson interferometer.
- The absorption is recorded as a function of time (as the mirror in one of the interferometer arms is moved).
- The resulting interferogram is then Fourier transformed into frequency space to obtain an absorption spectrum.
- The spectrum is sensitive to the vibrations of the molecular bonds of the sample material.
Ellipsometry

- Ellipsometry measures the change of the polarization of a beam upon reflection or transmission.
- Using equations that relate reflection coefficients to polarization, the technique gives direct measurement of the complex dielectric constant of the sample which includes information about the index of refraction and the absorption coefficient.
- Both of those quantities will depend on the surface composition, thickness and morphology.
- One can measure thicknesses much less than the wavelength of the light used.
Other Techniques

• The particular choice of excitation source and emission type will determine what the technique is sensitive to.

• Other than optical radiation, electron beams, x-rays and ion beams are available.
Electron Sources

- Electrons can be emitted from a metal by **thermionic emission**.
- A high enough electric field applied to the metal pulls electrons off the metal surface.
- The number of electrons emitted is proportional to the temperature of the metal and inversely proportional to its work function.

![Diagram of electron source and beam](image)
Electron Analyzers

- They use electrostatic or electromagnetic fields to deflect electrons and sort them according to their initial kinetic energy.
- Some types are:
  - Cylindrical Mirror Analyzer (CMA)
  - Hemispherical Sector Analyzer (HSA)
  - Retarding Field Analyzer (RFA)
  - Cylindrical Sector Analyzer (CSA)
Electron Detectors

- The detector receives electrons.
- Each electron contributes to a current that is measured.
- An amplification scheme is usually incorporated.
- Some types are:
  - Electron multiplier
  - Channeltron
  - Channel plate
X-Ray Sources

**Bremmstrahlung**

- Created by sudden stopping of electrons
- Suitable for small labs
- Low maintenance
- Complex emission spectrum
- Subject to contamination

**Synchrotron**

- Created by accelerated electrons
- National lab type facility
- High brilliance source
- Narrow, tunable lineshape
X-Ray Analyzers

• Wavelength Dispersive
  – Use a crystal and x-ray diffraction just like an optical spectrometer.
  – Very sensitive and precise but expensive and slow.

• Energy Dispersive
  – Use absorption in Si or Ge, generate multiple electron-hole pairs and separate them with an applied voltage.
  – Faster and cheaper but less sensitive.
X-Ray Detectors

• Scintillators and phosphors
  – X-rays are absorbed as they penetrate the detector and emit visible light.

• Calorimeters
  – X-rays are absorbed and the heat they produce is measured.

• Charge detectors
  – X-rays kick-off electrons from their orbits and the resultant current is measured.
<table>
<thead>
<tr>
<th>Technique</th>
<th>Send In</th>
<th>Detect</th>
<th>Notes</th>
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</thead>
<tbody>
<tr>
<td>Scanning Electron Microscopy</td>
<td>high energy electrons (30 keV)</td>
<td>backscattered and secondary electrons</td>
<td>High resolution imaging</td>
</tr>
<tr>
<td>Auger Electron Spectroscopy</td>
<td>moderate energy electrons (5 keV)</td>
<td>secondary electrons</td>
<td>Surface sensitive for chemical composition detection, can damage surface</td>
</tr>
<tr>
<td>X-ray Photoelectron Spectroscopy</td>
<td>light (X-rays - 1 keV)</td>
<td>secondary electrons</td>
<td>Low resolution, surface technique for chemical composition detection, minimal surface damage</td>
</tr>
<tr>
<td>X-ray Electron Spectroscopy</td>
<td>Electrons</td>
<td>X-rays</td>
<td>Deeper chemical composition detection, can be coupled with SEM</td>
</tr>
<tr>
<td>Low Energy Electron Diffraction</td>
<td>low energy electrons (100 eV)</td>
<td>diffracted electrons</td>
<td>Uses low energy electron diffraction for crystal structure measurement</td>
</tr>
<tr>
<td>Reflection High Energy Electron Diffraction</td>
<td>moderate energy electrons (5 keV)</td>
<td>diffracted electrons</td>
<td>Similar to LEED w/ high energy electrons</td>
</tr>
<tr>
<td>Secondary Ion Mass Spectrometry</td>
<td>moderate-high energy ions (2-30 keV)</td>
<td>secondary ions</td>
<td>Very sensitive surface chemical composition technique</td>
</tr>
<tr>
<td>Rutherford Backscattering</td>
<td>He Ions</td>
<td>Backscattered ions</td>
<td>Element type, concentration and depth information</td>
</tr>
</tbody>
</table>
Four Point Probe

• By separating the current application and voltage readout the effect of the probe resistance is minimized.

• The 4-point probe has 4 Tungsten probes in a line. The outer pair is for current application and the inner pair is for voltage readout.

• One would still need to do some “modeling” to extract useful information such as the resistivity or thickness.
Hall Effect

• A current is applied to the sample under a magnetic field.

• The electrons in motion are deflected by the magnetic field and start accumulating at one side of the film and therefore set up an electric field and a voltage difference.

• Information about the number of carriers, the type of carriers (electrons-holes) can be obtained.

\[ V_H = -\frac{IB}{dne} = R_H \frac{IB}{d} \]  

Hall voltage for a metal
Mechanical Measurements

- Internal - Residual Stress
- Indentation
- Friction and wear
- Adhesion